

Order for a research machine in China

Bezons, France, September 3rd – 5:45 pm – RIBER, the global leader for molecular beam epitaxy (MBE), is announcing the sale of a Compact 21 MBE machine to SITP (Shanghai Institute of Technical Physics) a famous material research institute in China.

SITP is a regular user of Riber MBE products specialized for the growth of thin film layers and quantum well structures.

This new Compact 21 system will enable the laboratory to increase its fundamental research capabilities on new III-V based structures.

This order strengthens Riber key position in the Chinese market which is the fastest-growing regions for the semi-conductor industry.

With a more than 800 MBE machines installed base and its successful industrial experience, RIBER is the leader of the MBE-based compound semiconductor deposition market.

About RIBER:

Riber designs and produces molecular beam epitaxy (MBE) systems as well as evaporation sources and cells for the semiconductor industry. This high-tech equipment is essential for the manufacturing of compound semiconductor materials and new materials that are used in numerous consumer applications, from new information technologies to OLED flat screens and new generation solar cells. RIBER recorded €29.0 million in revenues for 2011 and employs 100 people.

Riber is listed on Euronext Paris Compartment "C" and is part of the CAC Small, CAC Mid & Small, CAC Technology and CAC T. HARD. & EQ.

ISIN: FR0000075954 Reuters code: RIBE.PA Bloomberg code: RIB: FP

Riber is innovation certified by OSEO, the dedicated French innovation agency, enabling it to qualify for French innovation mutual funds (FCPI).

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